

EAST Search History

EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	83	(prevent\$3 or avoid\$3 or eliminat\$3) near3 (curtain) with ((inert or carrier or inactive or purge) adj2 gas or nitrogen or helium or argon)	US-PGPUB; USPAT; USOCR	OR	ON	2009/07/20 07:06
L2	60	1 and (substrate or wafer or glass)	US-PGPUB; USPAT; USOCR	OR	ON	2009/07/20 07:06
L3	3736	(prevent\$3 or avoid\$3 or eliminat\$3) near3 (backflow) with (pipe or tube or delivery or line)	US-PGPUB; USPAT; USOCR	OR	ON	2009/07/20 07:12
L4	796	3 and (substrate or wafer or glass)	US-PGPUB; USPAT; USOCR	OR	ON	2009/07/20 07:12
S37	0	"64037464"	JPO	OR	ON	2009/07/16 09:06
S38	76	teos near2 liquid near5 ((carrier or inert) adj gas)	US-PGPUB; USPAT; USOCR	OR	ON	2009/07/16 10:28
S39	47	(dichlorosilane or "SiH.sub.2Cl.sub.2" or monosilane or "SiH.sub.2" or silicon adj tetrachloride or "SiCl.sub.4") near2 ((liquid or precursor) near5 ((carrier or inert) adj gas)	US-PGPUB; USPAT; USOCR	OR	ON	2009/07/16 10:56
S40	173	("2001/0024387").URFN.	USPAT	OR	ON	2009/07/17 07:50
S41	14703	(prevent\$3 or avoid\$3 or eliminat\$3) near3 (backflow)	US-PGPUB; USPAT; USOCR	OR	ON	2009/07/17 11:07
S42	54	S41 and (ALD or atomic adj layer adj deposition)	US-PGPUB; USPAT; USOCR	OR	ON	2009/07/17 11:07

S43	170	(prevent\$3 or avoid\$3 or eliminat\$3) near3 (backflow) with ((inert or carrier or inactive or purge) adj2 gas or nitrogen or helium or argon)	US-PGPUB; USPAT; USOCR	OR	ON	2009/07/17 11:11
S44	91	S43 and (substrate or wafer or glass)	US-PGPUB; USPAT; USOCR	OR	ON	2009/07/17 11:11
S45	1560	(prevent\$3 or avoid\$3 or eliminat\$3) near3 (mixing or mixture) with ((inert or carrier or inactive or purge) adj2 gas or nitrogen or helium or argon)	US-PGPUB; USPAT; USOCR	OR	ON	2009/07/17 13:32
S46	743	S45 and (substrate or wafer or glass)	US-PGPUB; USPAT; USOCR	OR	ON	2009/07/17 13:32
S47	579	(prevent\$3 or avoid\$3 or eliminat\$3) near3 (mixing or mixture) near3 gas with ((inert or carrier or inactive or purge) adj2 gas or nitrogen or helium or argon)	US-PGPUB; USPAT; USOCR	OR	ON	2009/07/17 13:33
S48	332	S47 and (substrate or wafer or glass)	US-PGPUB; USPAT; USOCR	OR	ON	2009/07/17 13:33
S49	223	(prevent\$3 or avoid\$3 or eliminat\$3) near3 (mixing) near3 gas with ((inert or carrier or inactive or purge) adj2 gas or nitrogen or helium or argon)	US-PGPUB; USPAT; USOCR	OR	ON	2009/07/17 13:35
S50	152	S49 and (substrate or wafer or glass)	US-PGPUB; USPAT; USOCR	OR	ON	2009/07/17 13:35

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